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Electrical, optical and structural properties of Ga-Al doped ZnO/Copper/Ga-Al doped ZnO multilayer electrode for thin film solar cells

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We have investigated electrical, optical and structural properties of Ga-Al doped ZnO/Copper/Ga-Al doped ZnO multilayer electrode for thin film solar cells. The Ga-Al doped ZnO/Copper/Ga-Al doped ZnO multilayer films were deposited on polyethersulfone (PES) substrate at room temperature. The multilayer films consisted of intermediate Cu metal layers, top and bottom Ga-Al doped ZnO layer. The multilayer with PES substrate had advantages such as low sheet resistance, high optical transmittance in visible range and stable mechanical properties. From the results, sheet resistances of multilayer showed $12\Omega/\text{sq}$ with 9 nm of Cu metal layer thickness. Average optical transmittance of multilayer film showed 80% in visible range (380–770 nm) with 9 nm of Cu metal layer thickness. Moreover the multilayers showed stable mechanical properties than single-layered Ga-Al doped ZnO sample during the bending test due to the existence of ductile Cu metal layer.

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